

Product/Process Change (PCN) Notification

PCN Number: CO-10781 Date Issued: October 15 th , 2015 PCN Effective Date: December 4 th , 2015 Product(s) Affected: PE42420 Sample Availability: November 6 th , 2015 Change Control Board Approval #: CO-10781	Contact: Elizabeth La Greca Title: Director, Sales Operations Phone: 858-795-0106 Email: elagreca@psemi.com
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Change Category:

<input type="checkbox"/> Wafer Fabrication Process <input type="checkbox"/> Design/Mask Change <input type="checkbox"/> Singulation Process <input checked="" type="checkbox"/> Assembly Process – New package laminate <input type="checkbox"/> Electrical Test <input type="checkbox"/> Manufacturing Site	<input type="checkbox"/> Shipping/Labeling <input type="checkbox"/> Equipment <input type="checkbox"/> Material <input type="checkbox"/> Product Specification <input type="checkbox"/> Product End of Life <input checked="" type="checkbox"/> Other - Ordering Code
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Purpose of Change:

Transition to an improved laminate package material for PE42420.

Description of Change:

Assembly supplier discontinuing current production process (electroless NiAu - ENIG) laminate plating finish and transitioning to (electroless NiPdAu - ENEPIG), an industry standard. Peregrine is taking the opportunity to make this transition in order to assure ongoing laminate supply with improved solderability, reliability and performance.

Reliability, form, fit or function is not affected by this change

Beginning December 4th, 2015 all parts shipped to the customers will be manufactured with Magnachip wafers in the new package laminate.

Ordering Codes

Original ordering code: (Magnachip + ENIG plating finish): PE42420LGBB-Z, EK42420-02

New ordering code: (MagnaChip + ENEPIG plating finish): **PE42420C-Z, EK42420-03**

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Package Laminate Comparison

	Old Laminate	New Laminate
Surface Plating	ENIG	ENEPIG
Materials	Nickel, Gold	Nickel, Palladium, Gold
Ni Thickness	0.005mm min	0.003-0.006mm
PD Thickness	N.A	0.00005-0.0003mm
Gold Thickness	0.0003-0.00015 mm	0.00003mm min

Customer Acknowledgement of Receipt*:

<input type="checkbox"/> Change Denied <i>(Include explanation in comments section below)</i> <input type="checkbox"/> Change Approved	Name:	
	Title:	
	Company:	
	Date:	
	Signature:	
Customer Comments:		

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Appendix A


PE42420

Reliability Summary Report

Part Number(s):	PE42420	Product Family:	Switch
Package Type:	20L 4x4 FCLGA	MSL Rating:	3
Technology Platform:	ULTRACMOS®4		
Reliability Summary:	Based on the results of reliability testing, the PE42420 has met the reliability requirements for qualification.		

Table 1: Product Design Reliability Results

Test #	Test Performed	TEST METHOD/ Conditions	Duration	Req'd Sample Size ² (#LOT x SS)	Actual Sample Size ³ (#LOT x SS)	Result (RE./SS)
1	HTOL	Mil-Std-883 M1005.9/ JESD22-A108 VDD= 5.5V; VCTL= 3.6V; T _A = T _J = 150°C;	500 hrs.	1 x 77	3 x 80	<u>Passed</u> (0/240)
2	ESD HBM	Mil-Std-883 M3015	2.5kV	1 x 3 devices	1 x 10 devices	<u>Passed</u> (0/10)
3	ESD MM	JEDEC JESD22-A115	200V	1 x 3 devices	1 x 10 devices	<u>Passed</u> (0/10)

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Table 2: Bump Reliability Results

Test #	Test Performed	TEST METHOD/ Conditions	Duration	Req'd Sample Size ² (#LOT x SS)	Actual Sample Size ³ (#LOT x SS)	Result (REJ/SS)
4	HTS	Mil-Std-883 M1008.2/ JEDEC JESD22 A103 T _A = 175°C	500 hrs.	3 x 30 bumps	3 x 30 bumps	<u>Passed</u> (0/90)
5	TC ¹	Mil-Std-883 M1010.8/ JESD22-A104 T _A = -65°C to +150°C	500 cyc.	3 x 30 bumps	3 x 30 bumps	<u>Passed</u> (0/90)
6	Bump Dimensions	Mil-Std-883 M2016/ JESD22-B100	-	3 x 30 bumps	3 x 30 bumps	<u>Passed</u> (0/90)
7	Bumped Die Reflow Evaluation 1	IPC/JEDEC J-STD-020D.1 6x Reflow 260°C Peak	-	3 x 30 bumps	3 x 30 bumps	<u>Passed</u> (0/90)
8	Bumped Die Reflow Evaluation 2	IPC/JEDEC J-STD-020D.1 10x Reflow 260°C Peak	-	3 x 1 dice	3 x 1 dice	<u>Passed</u> (0/3)

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Table 3: Package Reliability Results

Test #	Test Performed	TEST METHOD/ Conditions	Duration	Req'd Sample Size ² (#LOT x SS)	Actual Sample Size ³ (#LOT x SS)	Result (REJ/SS)
9	HTOL	Mil-Std-883 M1005.9/ JESD22-A108 VDD= 5.5V; VCTL= 3.6V; T _A = T _J = 150°C;	500 hrs.	3 x 77	3 x 80	<u>Passed</u> (0/239) ⁵
10	HTS	Mil-Std-883 M1008.2/ JESD22-A103 T _A = 150°C	1,000 hrs.	1 x 77	3 x 95	<u>Passed</u> (0/285)
11	HAST ⁴	JESD22-A110 VDD= 3.6 V; VCTL= 3.6V; T _A = 110°C; RH= 85%; P _v = 1.204 atm	264 hrs.	3 x 45	3 x 46	<u>Passed</u> (0/138)
12	TC ⁴	Mil-Std-883 M1010.8/ JESD22-A104 T _A = -55°C to +125°C	1,000 cyc.	3 x 45	3 x 90	<u>Passed</u> (0/269) ⁵

Table 4: Package Assembly Level Reliability Results

Test #	Test Performed	TEST METHOD/ Conditions	Duration	Req'd Sample Size ² (#LOT x SS)	Actual Sample Size ³ (#LOT x SS)	Result (REJ/SS)
13	Physical Dimensions	Mil-Std-883 M2016/ JESD22-B100	-	3 x 10	3 x 10	<u>Passed</u> (0/30)
14	Die Peel	Subcon Specs.	-	3 x 2	3 x 2	<u>Passed</u> (0/6)
15	Solderability	Mil-Std-883 M2003.9/ JESD22-B102	-	3 x 3	3 x 5	<u>Passed</u> (0/15)

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Table 5: Wafer Process Reliability Results

Test #	Test Performed	TEST METHOD/ Conditions	Duration	Req'd Sample Size ² (#LOT x SS)	Actual Sample Size ³ (#LOT x SS)	Result (REJ/SS)
16	HTOL	Mil-Std-883 M1005.9/ JESD22-A108 VDD= 5.5V; VCTL= 3.6V; T _A = T _J = 150°C	500 hrs.	3 x 77 Devices	3 x 80 Devices	<u>Passed</u> (0/240)
17	HTS	Mil-Std-883 M1008.2/ JESD22-A103 T _A = 150°C	1,000 hrs.	1 x 77 Devices	1 x 77 Devices	<u>Passed</u> (0/77)
18	HAST ¹	JESD22-A110 T _A = 130°C; RH= 85%; P _v = 2.27 atm; biased	96 hrs.	3 x 45 Devices	3 x 45 Devices	<u>Passed</u> (0/135)
19	TC ¹	Mil-Std-883 M1010.8/ JESD22-A104 T _A = -65°C to +150°C	500 cyc.	3 x 45 Devices	3 x 45 Devices	<u>Passed</u> (0/135)
20	Electro- migration	Internal Specification Doc #57-0001	>T50	3 x 16	3 x 16	<u>Passed</u> (0/48)
21	Passivation Integrity	Mil-Std-883 M2021.3	-	1 wafer	1 wafer	<u>Passed</u> (0/1)
22	Destructive Analysis	Mil Std 883 M5009	N/A	1 wafer	1 wafer	<u>Passed</u> (0/1)
23	Hot Carrier	JESD28	>T50	1 wafer	1 wafer	<u>Passed</u> (0/1)
24	TDDB	JESD35	>T50	3 x 2 wafers	3 x 2 wafers	<u>Passed</u> (0/6)

¹ J-STD-020, Level-1 pre-conditioning applied: Moisture Soak at 85°C/85% RH for 168 hours. Reflow at 260±5/-0°C.

² Required sample size is based on Peregrine Semiconductor's Internal Reliability qualification requirements.

³ Actual sample size may be more than the required sample size to maximize the use of Reliability hardware.

⁴ J-STD-020, Level-3 pre-conditioning applied: Moisture Soak at 30°C/60% RH for 192 hours. Reflow at 260±5/-0°C.

⁵ one or more device (s) discounted due to non-process related failure..